

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	2129	((umoly or moly or molybdenum) and etch\$3).clm.	US-PGPUB; USPAT	OR	OFF	2005/10/23 18:01
S2	767	((umoly or moly or molybdenum) and etch\$3 and mask).clm.	US-PGPUB; USPAT	OR	OFF	2005/10/19 17:46
S3	169	((umoly or moly or molybdenum) and etch\$3 and mask and \$5esist).clm.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:12
S4	154	((umoly or moly or molybdenum) and etch\$3 and mask)	JPO	OR	OFF	2005/10/19 17:51
S5	5	((umoly or moly or molybdenum) and etch\$3 and mask)	EPO	OR	OFF	2005/10/19 17:46
S6	159	((umoly or moly or molybdenum) and etch\$3 and mask)	DERWENT	OR	OFF	2005/10/19 17:46
S7	80	((umoly or moly or molybdenum) and etch\$3 and mask)	IBM_TDB	OR	OFF	2005/10/19 17:55
S8	407	(216/12).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/19 17:48
S9	770	(430/4).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/19 17:48
S10	7631	(430/5).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/10/19 17:49
S11	64	((umoly or moly or molybdenum) and etch\$3 and spray\$3).clm.	US-PGPUB; USPAT	OR	OFF	2005/10/19 17:51
S12	158	((umoly or moly or molybdenum) and etch\$3 and \$5resist)	JPO	OR	OFF	2005/10/19 17:52
S13	97	((umoly or moly or molybdenum) and etch\$3 and (mask or \$5resist))	IBM_TDB	OR	OFF	2005/11/14 11:11
S14	53	((umoly or moly or molybdenum) and etch\$3 and hydroxide).clm.	US-PGPUB; USPAT	OR	OFF	2005/10/19 17:59
S15	1	(umoly and mask)	US-PGPUB; USPAT	OR	OFF	2005/10/23 18:01
S16	7670	(430/5).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/14 11:10

S17	770	(430/4).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/14 11:11
S18	407	(216/12).CCLS.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/14 11:11
S19	97	(((\$5moly or moly or molybdenum) and etch\$3 and (mask or \$5resist))	IBM_TDB	OR	OFF	2005/11/14 11:11
S20	169	(((\$5moly or moly or molybdenum) and etch\$3 and mask and \$5esist).clm.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:46
S21	11241	(((\$5moly or moly or molybdenum) and etch\$3 and mask\$3 and \$5resist)	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:13
S22	444	(((\$5moly or moly or molybdenum) and etch\$3 and mask\$3 and \$5resist).clm.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:38
S23	23	(((\$5moly or moly or molybdenum).ti. and etch\$3 and mask\$3 and \$5resist)	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:18
S24	32	(((\$5moly or moly or molybdenum).ti. and etch\$3 and mask\$3 and \$5resist)	EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/11/14 11:19
S25	18	(((\$5moly or moly or molybdenum) near3 mask\$3) and etch\$3 and \$5resist).clm.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:40
S26	15	(((\$5moly or moly or molybdenum) near3 mask) and etch\$3 and \$5resist).clm.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:27
S27	90	S22 and (S16 S17 S18)	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:39
S28	11	S22 and (S16 S17 S18) and (thick).clm.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:40
S30	170	(((\$5moly or moly or molybdenum) near3 mask\$3) and etch\$3 and \$5resist and (thick\$4 and diameter)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/11/14 11:47
S31	377	(((\$5moly or moly or molybdenum) near3 mask\$3) and etch\$3 and \$5resist and (thick\$4 or diameter)	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/11/14 11:42
S32	7	(((\$5moly or moly or molybdenum) near3 mask\$3) and etch\$3 and \$5resist and (thick\$4 or diameter)	EPO; JPO; DERWENT	OR	OFF	2005/11/14 11:43
S33	6	(((\$5moly or moly or molybdenum) near3 mask\$3) and etch\$3 and \$5resist and (thick\$4 or diameter)).clm.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:42

S34	113	((berasi near2 peter) (michael near2 jerome) (doris near2 pulaski) (rippstein near2 robert)).in.	US-PGPUB; USPAT	OR	OFF	2005/11/14 11:47
S35	13	(mask or \$5moly or moly or molybdenum) and S34	US-PGPUB; USPAT; EPO; JPO; DERWENT	OR	OFF	2005/11/14 11:48